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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.: **10/549,609**

Filing Date: September 20, 2005

Applicant: Tomoko AKAI et al.

Conf. No.: 8155

Group Art Unit: 1791

Examiner: Margaret Brodie

Title: METHOD FOR PRODUCING HIGH SILICATE GLASS
AND HIGH SILICATE GLASS (as amended)

Atty. Dkt. No.: 12480-000144/US

Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314
Mail Stop **Amendment**

December 8, 2009

RESPONSE TO RESTRICTION REQUIREMENT & STATEMENT UNDER 37
C.F.R. §1.113(b)

Sir:

In response to the Restriction Requirement mailed on November 9, 2009 and the Interview Summary mailed on November 19, 2009, the following remarks are respectfully submitted in connection with the above-referenced patent application.

	Claims remaining after Response		Highest number previously paid for		Present extra
Total	19	-	20	=	0
Independent	1	-	3	=	0